CS-01-208

December 12, 2003

To: Commissioner for Patents
P.O. Box 1450
Alexandria, VA 22313-1450

Fr: George O. Saile, Reg. No. 19,572
28 Davis Avenue
Poughkeepsie, N.Y. 12603

Subject: Serial No. 10/664,210 09/17/03

Yong Meng Lee et al.

METHOD OF FORMING DOUBLE-GATE SEMICONDUCTOR-ON-INSULATOR (SOI) TRANSISTORS

INFORMATION DISCLOSURE STATEMENT

Enclosed is Form PTO-1449, Information Disclosure Citation In An Application.

The following Patents and/or Publications are submitted to comply with the duty of disclosure under CFR 1.97-1.99 and 37 CFR 1.56.

CERTIFICATE OF MAILING

I hereby certify that this correspondence is being deposited with the United States Postal Service as first class mail in an envelope addressed to: Commissioner for Patents, P.O. Box 1450, Alexandria, VA 22313-1450, on December 19, 2003.

Stephen B. Ackerman, Reg.# 37761

Signature/Date 12/19/03

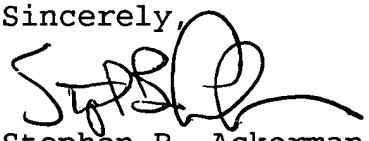
U.S. Patent 6,451,656 to Yu et al., "CMOS Inverter Configured From Double Gate MOSFET and Method of Fabricating Same," describes a double-gate transistor on semiconductor-on-insulator (SOI).

U.S. Patent 6,413,802 to Hu et al., "FinFET Transistor Structures Having a Double Gate Channel Extending Vertically From a Substrate and Methods of Manufacture," describes a double-gate FinFET on semiconductor-on-insulator (SOI).

U.S. Patent 6,365,465 to Chan et al., "Self-Aligned Double-Gate MOSFET by Selective Epitaxy and Silicon Wafer Bonding Techniques," describes a process for a double gate MOSFET on semiconductor-on insulator (SOI).

U.S. Patent 6,396,108 to Krivokapic et al., "Self-Aligned Double Gate Silicon-On-Insulator (SOI) Device," describes a process for a double gate MOSFET on semiconductor-on-insulator (SOI).

Sincerely,



Stephen B. Ackerman,
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Form PTO-1449

INFORMATION DISCLOSURE CITATION IN AN APPLICATION

(Use several sheets if necessary)

Docket Number (Optional)	Application Number
CS-01-208	10/664,210
Applicant: Yong Meng Lee et al.	
Filing Date: 09/17/03	Group Art Unit:

U. S. PATENT DOCUMENTS

Examiner Initial	Document Number	Date	Name	Class	Subclass	Filing Date if Appropriate
	6451656	9/17/02	Yu et al.	438	283	2/28/01
	6413802	7/2/02	Hu et al.	438	151	10/23/00
	6365465	4/2/02	Chan et al.	438	283	3/19/99
	6396108	5/28/02	Krivokapic et al.	257	365	11/13/00

FOREIGN PATENT DOCUMENTS

Examiner Initial	Document Number	Date	Country	Class	Subclass	Translation YES	Translation NO

OTHER DOCUMENTS (Including Author, Title, Date, Pertinent Pages, Etc.)

EXAMINER	DATE CONSIDERED

EXAMINER: Initial if citation considered, whether or not citation is in conformance with MPEP § 609; Draw line through citation if not in conformance and not considered. Include copy of this form with next communication to the applicant.